# Advanced Beam Diagnostics Tools for the SwissFEL Project

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## Outlook

- Introduction/ SwissFEL Project Overview
- SwissFEL Beam Diagnostics Tools
- Summary/Conclusions

### **SwissFEL location**

# Paul Scherrer Institute, near Zurich, Switzerland, Europe



#### SwissFEL – a hard X-ray (0.1 nm) SASE FEL at PSI, Switzerland

# SASE\* (Self Amplified Spontaneous Emission) FEL



- relativistic electron bunch
- a (long enough) undulator

$$\vec{B} = \left(0, \vec{B}_u \sin k_u z, 0\right)$$
$$k_u = \frac{2\pi}{\lambda_u}$$

\*) Kondratenko, Saldin 1980 Derbenev, Kondratenko, Saldin 1982 Bonifacio, Pellegrini, Narducci 1984

# SASE (Self Amplified Spontaneous Emission) FEL



- In the undulator, the bunch is modulated by its own synchrotron radiation field
- Electrons are "self-organized" in micro-bunches, which radiate coherently
- The total radiated power grows exponentially until it reaches saturation



## **SASE FEL performance conditions**

$$\vec{B} = \left(0, \vec{B}_u \sin k_u z, 0\right)$$

$$x(z) = x_0 \sin k_u z$$
$$k_u = \frac{2\pi}{\lambda_u}$$

-

#### - A resonant condition in the undulator

$$\lambda_0 = \frac{\lambda_u}{2\gamma^2} \left( 1 + \frac{K^2}{2} \right)$$

$$K = \frac{eB_u \lambda_u}{2\pi mc} \approx 0.93 \ \lambda_u \ [\text{cm}] \ B_u \ [\text{T}]$$

undulator parameter

Parameters for lasing at 1 Å			
Beam energy	5.8 GeV		
λυ	15 mm		
К	1.2		



 A sufficient overlap between the electron bunch and its radiation field



A bright source with small  $\varepsilon_N$ or high energy









#### **FEL parameter**

for VUV FELs ~ 0.01-0.001 SwissFEL (0.1 nm) ~ 0.0003



log(power)

# So, SASE FEL requires



- Small bunch length
  - Small transverse bunch size
- Very precise beam steering through the accelerator and (long) undulator

#### <u>SwissFEL</u> – <u>a "compact" hard X-ray SASE FEL @ PSI, Switzerland</u>

 $\rightarrow$  building length: ~700 m  $\rightarrow$  construction period: 2012 – 2017



#### **X-FEL Facilities**

ies				+
	LCLS (USA)	SACLA (Japan)	European XFEL	SwissFEL (CH)
Start of operation	2009	2011	2017	2017
Length [km]	3.0	0.75	3.4	0.75
Beam energy [GeV]	13.6	8	17.5	5.8
Min. wavelength [nm]	0.15	0.1	0.1	0.1
Peak brilliance at λ <sub>min</sub> [10³³ photons/s/mm²/mrad²/0.1% BW]	2.4	5.0	5.0	1.3

SwissFEL has the lowest beam energy (optimized for 1Å)

- Advantages: Compact and affordable for Switzerland
- Challenges : More stringent requirements for the beam quality, mechanical and electronic tolerances

For availability/costs reasons the injector is <u>European S/X band</u>, whereas the linac is <u>US C band</u>

Frequencies in MHz			SwissFEL frequencies	
		«European»	«American»	f <sub>b</sub> =142.8
	S-Band	2997.912 Already procured	2856	2998.8 (21xf <sub>b</sub> )
Injector	X-Band (4 x S-band)	11991.648 Already procured	11424	11995.2 (84xf <sub>b</sub> )
Main linac	C-Band (2 x S-band )	5998.524 requires development of klystron with PSI presently the only customer	5712 Klystron available almost "off the shelf" Spring8, KEK, LNF are already customers	5712 (40xf <sub>b</sub> )

Common sub-harmonic 142.8MHz, minimum bunch spacing 7 ns

# **SwissFEL Highlights**

- Two FEL Beamlines:
  - Hard X-ray Beamline Aramis: SASE FEL (1 7 Å), tuning mostly by energy
  - Soft X-ray Beamline Athos: SASE FEL (7 70 Å), seeded FEL (10 70 Å), tuning by gap and energy
  - Possible future extension for another hard or soft X-ray beamline (Porthos)
- Electron Beam:
- 10 200 pC, 2.1- 5.8 GeV, 1.5 3 kA, 0.15 0.43 mm mrad, Energy spread 300 keV



### SwissFEL Machine/Beam Diagnostics Design/Development Resources

#### SwissFEL Injector Test Facility (SITF): 250 MeV Machine



#### **Other FEL Facilities Worldwide**

- LCLS, USA
- SACLA, Japan

- FERMI, Italy
- FLASH, Germany

### SwissFEL Diagnostics Challenges – Key Beam Parameters

- $\rightarrow$  low charge (10 pC) capability for all diagnostics monitors
- $\rightarrow$  high bandwidth pick-ups and detectors to accommodate for 2-bunch mode ( $\Delta \tau = 28 \text{ ns}$ )
- → low emittance beam ( $\epsilon_n \ge 180$  nm rad) generating small transverse beam sizes
- $\rightarrow$  ultra-short bunches (2.5 fs <  $\tau$  < 20 fs) and high compression factors
- $\rightarrow$  ultra-low synchronization and timing (as well as RF) jitter tolerances
- → all monitors must be capable of being used in (beam-based) real-time feedbacks

SwissFEL	Operation Modes		SwissFEL	Operation Modes	
Key Parameters	Long Bunch	Short Bunch	Key Parameters	Long Bunch	Short Bunch
Photon Energy	0.2 – 12 keV (1 Å)	0.2 – 12 keV (1 Å)	Bunch Length	20 fs (rms)	2.5 fs (rms)
Power / Energy	60 µJ / 2 GW	3 µJ / 0.6 GW	Comp. Factors	125	240
Electron Energy	5.8 GeV (for 1 Å)	5.8 GeV (for 1 Å)	Norm. ε <sub>h,ν</sub>	430 nmrad	180 nmrad
Bunch Charge	200 pC	10 pC	Timing Stability	Jitter	Drift
Rep. Rate	100 Hz	100 Hz	Sync. System	< 10 fs	< 20 fs / day
Bunch Distance	28 ns (2 bunches)	28 ns (2 bunches)	Bunch Arrival	< 10 fs	< 10 fs / day

### **Beam Charge Monitors**

Main SwissFEL requirements:

- Absolute charge (10-200 pC) measurement accuracy 1%
- 2-bunch resolving capability

### **Bergoz Turbo-ICT-2**



- Delivered as a fully calibrated device
- Not sensitive to the dark current due to its fast readout of the beam induced current (3 ns) at higher bandwidth



- Integration time is reduced by 25 compared to traditional ICT.
  Bandwidth increase is achieved by using low-loss core alloy.
- ⇒ Signal increases by 25 and noise by √25. Hence signal over noise ratio increases by 5.
- Multiple cores could be used to catch more signal from beam. The core windings outputs are combined to optimize the power transmission from cores to front-end amplifier.

- Readout cores are coupled to a low noise amplifier. Impedance is chosen to optimize signal over noise performance.
- Narrow-band processing. The wide-band signal from the amplifier is converted to a 100-325 MHz single tone resonance. Apex amplitude is proportional to the bunch charge.
- $\Rightarrow$ increases noise immunity.
- $\Rightarrow$  decreases insertion losses in cable.
- $\Rightarrow$  improves impedance matching.

# **Turbo ICT Installed in SITF**



### **Beam Position Monitors**

# **Requirements / Specifications**

<u>Parameter</u>	<u>Injector</u>	Linac & TL	<u>Undulators</u>
Pickup Length	250 mm	100 mm	100 mm
Inner Beam Pipe Aperture	38 mm	16 mm	8 mm
Position Range	±10 mm	±5 mm	±1 mm
RMS Position Noise	<10 µm	<5 µm	<1 µm
Position Drift (per week)	<10 µm	<5 µm	<1 µm
Relative RMS Charge Noise	<0.1%	<0.1%	<0.1%
Nominal Charge	10-200 pC		
# Bunches per Train	1-3		1
Max. Bunch Train Rep Rate	100Hz		
Min. Bunch Spacing	( 28 ns )		-

# Solution

#### Pickups:

 Use only cavity BPMs (based on E-XFEL/SACLA design optimized for low charge operations) to minimize manpower & to get a homogeneous system.

#### Electronics:

 Based on E-XFEL electronics (PSI, Swiss in-kind contribution to the European project).
Small modifications are made to meet SwissFEL specs.

#### **Resonant Cavity in Accelerators**



- Passing a pillbox-like resonant cavity the electron bunch excites several resonance modes

-- short bunches deliver a wide spectrum of frequencies

#### RF-BPM (similar designs for SCSS, European-XFEL, SwissFEL)



Beam Position =  $k * (V_{Pos_{Cav}} / V_{Ref_{Cav}})$ . Factor k: Not fixed, variable via attenuator.

\*The identical frequencies of the position and reference cavities modes minimize the impact of the frequency dependent gain drift on the position readings.

#### SwissFEL Beam Position Monitor System



## Cavity BPM Signal Processing Electronics as a Modular Topology of SwissFEL Diagnostics Systems

Based on the latest FPGA technology (Kintex-7/Artix-7)







#### SwissFEL Beam Position Monitor System

<u>Parameter</u>	Injector, I	<u>Undulators</u>	
Pickup Name (Number = Aperture in mm)	BPM38	BPM16	BPM8
Pickup Length	250 mm	100 mm	100 mm
Resonant Frequency	3.2844 GHz	3.2844 GHz	4.9266 GHz
Quality factor	40 (low-Q)	40 (low-Q)	1000 (high-Q)
Quantity Installed in Machine (Phase 1)	7	111	27
Position Range	±10 mm	±5 mm	±1 mm
<b>RMS Position Noise</b>	<u>&lt;10 µm</u>	<u>&lt;5 µm</u>	<u>&lt;1 µm</u>
Position Drift (per week)	<10 µm	<5 µm	<1 µm
Relative RMS Charge Noise	<0.1%	<0.1%	<0.1%
# Bunches per Train	1-3 (Test: SITF 1-2)		1
Min. Bunch Spacing	28 ns		-

<u>Beam Tests</u>: sub-µm position resolution and ~ 10 fC charge noise





smaller  $\mathbf{Q}_{\mathbf{L}}$  for higher damping rate



## **Beam Position Monitor Project Outcome**

## **Standard SwissFEL Beam Diagnostics Electronics**


# **Transversal Beam Diagnostics Monitors**



# **Wire Scanners**

# **Wire Scanner Characteristics**



## **Typical Electron Beam Size: 5-500 μm**

## Number of Wires per Frame:

- > 3 + 3 (spare or different resolution)
- 3 possible wire separation (to speed-up the scan time)
- X, X-Y& Y scan in sequence

## Wire Specifics and Resolution:

- ➤ W (Tungsten) wires
- ➢ Diameter = 5-25 µm
- > Resolution (RMS)= 1.5-6.5  $\mu$ m

**Encoder Resolution:** 

>0.1 µm (absolute position)

# **Technical Realization**





It was demonstrated that in the wire velocity range 0.2-2 mm/sec the wire vibration is below the intrinsic resolution limits.

Al:Si wires of 12.5 micrometer thickness are possible candidates for the undulator areas.

# **Beam Loss Monitors**

# Localized BLMs (wire scanner support)

- Must provide online beam size measurements by recording losses due to wire insertions
- Requirements

Full beam loss event / bunch10...200 pCWire scanner operations0.1...20 pCOperational requirements:Synchronized DAQ @ 100 HzInterface to Machine Protection System (all BLMs)Ability to resolve 2 bunches

# **Optical Fiber Based Systems**

- Scintillating Plastic Optical Fibers (POF)
- Flexible
- Cost effective
- Clear waveguides can be used to carry signals out of the accelerator tunnel
- Radiation resistant (>20% trans. scint. loss) > 400 Rad for various scintillating POF

 $\rightarrow$  radiation hard (1 MRad) versions also exist



# **Optical Fiber Based Systems**

- POF fibers for SwissFEL Saint Gobain Crystals
  - 1 mm diameter polystyrene scintillator fibers
  - Characteristic signal decay time ~ 2.7 ns
  - Emission wavelength: visible
  - Photon yield in plastic scintillator: 8000/MeV
  - 1/e length ~ 3.5m
  - Core refractive index 1.5-1.6
- Can differentiate signal from the dark current
- Can detect wire losses down to the input bunch charge of 1pC





# Localized BLMs



# Localized BLMs



# Distributed BLMs (for machine interlocks)

Based on Cherenkov radiation generated by lost particles in long optical fibers (quartz) installed along the accelerator.







## **Example: beam loss distribution in SITF**

# **Transverse Profile Imagers**

## > SR/DR/ER monitors

# ≻ OTR

Scintillator Screens

## **Optical Transition Radiators as 2D Transverse Profile Monitors**

## Schematic Set-Up and Main Properties of OTR as Screen Monitors



- OTR is generated when relativistic charged particles pass the boundary of two media with different dielectric (optical) properties
- > OTR screen could be a thin metal foil or silicon wafer (with Al layer)
- > OTR is radiated in forward and backward direction with an opening angle of  $1/\gamma$
- > incoherent Optical TR provides good linearity for profile measurements
- > surface quality of OTR screen affects profile imaging quality (beam size)

## **Optical Transition Radiators as 2D Transverse Profile Monitors**







<u>Coherent OTR images from LCLS</u> showing full saturation of camera

H. Loos, et al., LCLS

# The PROBLEM:

Coherent OTR has been observed for highly brilliant electron beams

Coherent OTR was first observed at LCLS

SACLA and FLASH validated COTR observations

So, to measure profiles with wire scanners? but it is very slow...

Another option – to use scintillator screens (also affected by the COTR) and try to suppress the generated COTR.

# Scintillator Screens as 2D Transverse Profile Monitors (YAG or LuAG scintillator crystals)

## Schematic Set-Up and Main Properties of Scintillators as Screen Monitors



- electrons passing the scintillator crystal excite atoms and molecules, which then scintillate: re-emit the energy in the form of light
- $\succ$  visible light from scintillator crystals is radiated in  $4\pi$
- photons are created along the beam pass through scintillator crystal
  a "light column" is formed



- > scintillator crystals are very sensitive and radiation resistant
- > multiple scattering in scintillator crystal increases beam divergence
- > thickness of scintillator crystals and observation angles affect resolution

COTR is formed at the border scintillator/vacuum



- OTR is an instantaneous process
- Coherent OTR produces in case of micro-bunching
- Scintillation has a "long" decay time
- Scintillation is not sensitive to micro-bunching

## **<u>COTR Suppression:</u>** Temporal Separation with Scintillator & Gated CCD

## COTR Mitigation Tests @ FLASH using Scintillator and ICCD (Minjie Yan et al., FLASH, Hamburg)



#### (b) OTR screen, +100ns delay

(d) LuAG screen, +100ns delay

## no delay at ICCD

- COTR and CSR on OTR screen
- COTR and CSR on scintillator (LuAG screen)

## 100 ns delay at ICCD

- no signal from OTR screen
- Scintillation light only from LuAG screen



## **<u>COTR Suppression:</u>** Spatial Separation – Central Mask in Imaging System

- > OTR is emitted at an angle  $\Theta \sim 1/\gamma$
- > at beam energies > 1 GeV :  $\Theta$  < 0.5 mrad
- > scintillation light is emitted in  $4\pi$
- central mask in imaging system successfully suppresses COTR intensity



## COTR Mitigation @ SACLA using Scintillator and Spatial Mask (S. Matsubara et al., Spring8, Japan)



Image of vertically focused beam behind SACLA BC-3 (full compression)



Position [um]

## **<u>COTR Suppression:</u>** Spatial Separation – SwissFEL Profile Monitors



## **<u>COTR Suppression:</u>** Spatial Separation – SwissFEL Profile Monitors

## COTR Mitigation for SwissFEL Screen Monitors







# **Bunch Compression Monitor**

## **Coherent Radiation Based Diagnostics**



## Bunch radiation spectrum

$$\frac{\mathrm{d}U}{\mathrm{d}\lambda} = \left(\frac{\mathrm{d}U}{\mathrm{d}\lambda}\right)_0 \left(N + N(N-1) |F(\lambda)|^2\right)$$

## where

 $(\mathrm{d}U/\mathrm{d}\lambda)_0$ 

# is emission spectrum of one electron and

$$F(\lambda) = \int_{-\infty}^{\infty} S(z) \exp\left(\frac{-2\pi \mathrm{i}}{\lambda} z\right) \mathrm{d}z$$

is the bunch form factor

## **Coherent Radiation Based Diagnostics**



Bunch radiation spectrum

$$\frac{\mathrm{d}U}{\mathrm{d}\lambda} = \left(\frac{\mathrm{d}U}{\mathrm{d}\lambda}\right)_0 \left(N + N(N-1) |F(\lambda)|^2\right)$$

# $10^{2} - 10^{1} - 1$

### where

Fig. 1 Plot of Power vs. Wavelength for Injector CSR Port

 $(\mathrm{d}U/\mathrm{d}\lambda)_0$ 

# is emission spectrum of one electron and

$$F(\lambda) = \int_{-\infty}^{\infty} S(z) \exp\left(\frac{-2\pi \mathrm{i}}{\lambda}z\right) \mathrm{d}z$$

is the bunch form factor

## SwissFEL BC-1 THz Compression Monitor

- use of coherent edge radiation from 4<sup>th</sup> BC-1 diplole (non-invasive)
- two signal paths for observation of different spectral (THz-) ranges for sensitivity to different bunch lengths
- use of THz high pass filters and broadband Schottky diodes
- ND-filters for intensity adjustment (bunch charge range: 10 200 pC)
- read-out electronics similar to button-type BPM RF front end





## SwissFEL BC-1 THz Compression Monitor

- quasi-linear behaviour of Schottky diode signals within the nominal operation range of BC-1 compression monitor (10 – 200 pC)
- SwissFEL operation modes with 2-bunches (@ 28 ns bunch distance) and low charge (10 pC) are feasible with Schottky diodes



	NEP W/Hz <sup>1/2</sup>	Responsivity V/W	Response Time (seconds)	Operating Temp (K)
Golay cells [3]	10-10	105	10-2	300
Pyroelectrics [4]	10-10	10 <sup>5</sup>	10.5	240-350
Schottky diodes [5]	10-12	10 <sup>3</sup>	10-12	10-420

Table 1 - Commercially Available Room Temperature THz Detectors

# Summary

# Overview of SwissFEL Diagnostics Components (Phase-1, ARAMIS)

- → <u>Beam Position Monitors</u>:
- → <u>Screen Monitors</u>:
- → Wire Scanners:
- → Synchrotron Radiation Monitors::
- → Beam Charge Monitors:
- → Beam Loss Monitors:
- → Dose Rate Monitors:
- → Bunch Arrival Time Monitors:
- → Gun Laser Arrival Time Monitor:
- → <u>Compression Monitors</u>:
- → Transverse Deflectors:

- 7 × BPM-38 / 111 × BPM-16 / 27 × BPM-8 (all cavity-type BPMs) 10 × high sensitivity, high resolution SCM for meas. at 100 Hz 14 × SCM for observation and control room support at 10 Hz 23 × WSC along LINACs, TLs and ARAMIS Undulators 1 × BC-1 / 1 × BC-2 / 1 × Collimator (10<sup>-4</sup> energy spread res.) 4 × Turbo-ICT-2 (~ 4 % absolute)
- 145 × BPMs (0.1% relative)
- 38 scintillating monitors (high sensitivity)8 distributed Cherenkov monitors
- 32 Rad FET dose rate monitors (FERMI-type)
- 4 × BAMs (in front of LH, BC-2 & collimator, behind ARAMIS undulators)
- 1 × LAM at photo-injector gun
- 1 × BC-1 (THz) / 1 × BC-2 (FIR) / 1 × Collimator (FIR to visible) 2 coherent diffraction radiation monitors (for commissioning)
- 1 × S-band (behind BC-1 at 450 MeV providing 15 fs time resolution)
- 1 × C-band (behind LINAC-3 at 5.8 GeV providing ~ 2 fs time resolution)

# References

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- V. Arsov, P. Peier, F. Muller, F. Frei, S. Hunziker,
- B. Beutner, M. Kaiser, C. Ozkan, F. Lohl



## U15 parameters

Туре	Hybrid - In Vacuum							
# units	12							
Period		mm						
# periods								
Magnetic length		mm						
K-values	1.8	1.4	1.2	1.0	-			
GAP	3.2*	4.2	4.7	5.5	mm			
Bz max	1.27	1	0.85	0.7	Т			
Br		Т						
HcJ		kA/m						
Magnet size		mm						
Pole size	WE	mm						
Max GAP		mm						
ΔGAP		μm						

\*Minimum magnetic GAP (Vacuum GAP=3mm)






## Robot adjusting magnet positions in the SwissFEL undulator

